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|                               | SIDET NAMED INVENTOR                 | ATTORNEY DOCKET NO.  | CONFIRMATION NO.  |  |  |
|-------------------------------|--------------------------------------|--|---|--|--|
| FILING DATE                   | Nobuyuki Sekikawa                    | 402222002200   | 7319  |  |  |
| 10/19/2001                    |                                      | 492322002200   |   |  |  |
| 7590 10/23/2002               |                                      |  | EXAMINER  |  |  |
| & FOERSTER<br>lvd.            |                                      | VU, DAVID  |   |  |  |
| Suite 300<br>McLean, VA 22102 |                                      | ART UNIT   | PAPER NUMBER  |  |  |
|                               |                                      | 2818   |   |  |  |
|                               |                                      | DATE MAILED: 10/23/2002  |   |  |  |
|                               | 590 10/23/2002<br>& FOERSTER<br>lvd. | 10/19/2001 Nobuyuki Sekikawa<br>590 10/23/2002<br>& FOERSTER<br>lvd. | FILING DATE FIRST NAMED INVESTOR  10/19/2001 Nobuyuki Sekikawa 492322002200  590 10/23/2002  & FOERSTER VU, D  22102 ART UNIT |  |  |

Please find below and/or attached an Office communication concerning this application or proceeding.

|   |   |   |   |  | WW                 |
|---|---|---|---|--|--------------------|
| <u>.                                    </u>                              |   | Application No.   |   | Applicant(s)   |                    |
|   |   | 09/981,889  | !   | SEKIKAWA ET AL   |                    |
|   | Office Action Summary   | Examiner  |   | Art Unit   |                    |
|   |   | DAVID VU  |   | 2818   |                    |
|   | The MAILING DATE of this communication ap   | pears on the cover s  | sheet with the o  | orrespondence ad   | dress              |
| A SHC THE M - Extens after S - If the p - If NO - Failure - Any re earner |   | Y IS SET TO EXPI<br>136(a). In no event, howev<br>by within the statutory minin<br>will apply and will expire S | RE 3 MONTH<br>er, may a reply be tin<br>num of thirty (30) da<br>IX (6) MONTHS fron | (S) FROM  mely filed  ys will be considered time!  the mailing date of this or | <b>v</b>           |
| tatus   | Responsive to communication(s) filed on 05  | September 2002  |   |  |                    |
| 1)⊠   | \ <b>\</b> \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \  | his action is non-fir   | nal.  |  |                    |
| 2a)□<br>3)□<br>ispositi   | Since this application is in condition for allow closed in accordance with the practice unde on of Claims   | vance except for for<br>er Ex parte Quayle,   | rmal matters. I   | orosecution as to th<br>453 O.G. 213.  | ne merits is       |
| 4)🛛   | Claim(s) 1-13 is/are pending in the application   | on.   |   |  |                    |
|   | 4a) Of the above claim(s) <u>6-13</u> is/are withdraw   | wn from considerati   | on.   |  |                    |
| 5)  | Claim(s) is/are allowed.  |   |   |  |                    |
| 6)🛛   | Claim(s) 1-5 is/are rejected.   |   |   |  |                    |
| 7)  | Claim(s) is/are objected to.  |   |   |  |                    |
| 8)[]  | Claim(s) are subject to restriction and   | l/or election require   | ment.   |  | •                  |
| Applicat  | ion Papers  |   |   |  |                    |
| 9)[   | The specification is objected to by the Exami   | iiei.<br>••••••••••••••••••••••••••••••••••   | h) objected t   | o by the Examiner  |                    |
| 10)⊠  | The drawing(s) filed on 19 October 2001 is/a  | the drawing(s) he he  | اط in abevance.   | See 37 CFR 1.85(a  | ).                 |
|   | Applicant may not request that any objection to   | is: a) \ annrov   | ed b)∏ disapı   | proved by the Exam   | iner.              |
| 11)[  | The proposed drawing correction filed on  |   |   | · · · · · ·  |                    |
|   | If approved, corrected drawings are required in   | Examiner  | = - <del>=</del> - · · ·  |  |                    |
|   | The oath or declaration is objected to by the   | LAMINIO.  |   |  |                    |
| Priority  | under 35 U.S.C. §§ 119 and 120  | ···· - sissibu undar 3  | 5USC 811  | 9(a)-(d) or (f).   |                    |
|   | Acknowledgment is made of a claim for fore  | eign priority under 3   | ,,, o,,o,,o,, g, r r  | -(-) (-) ()  |                    |
| а   | ı)⊠ All b)□ Some * c)□ None of:   | and have been rec   | oived   |  |                    |
|   | 1.⊠ Certified copies of the priority docum  | ents have been rec  | eived in Annlie   | cation No.   |                    |
|   | Certified copies of the priority docum  | ents nave been rec  | civen iii Whaii   | eived in this Nation   | al Stage           |
| •   | 3. Copies of the certified copies of the papplication from the International See the attached detailed Office action for a                        | list of the certified   | copies not rece   | eived.   |                    |
| 14)   | A aknowledgment is made of a claim for dom  | estic priority under  | 35 U.S.C. § 1   | 19(e) (to a provisio   | nai application    |
|   | a) ☐ The translation of the foreign language ☐ Acknowledgment is made of a claim for don  | v provisional applica   | יים של המון וומט שביי   | 1CCCIVCU.  |                    |
| Attachm   |   | -   |   |  | · No(s).           |
| 1) 🛛 No   | otice of References Cited (PTO-892) otice of Draftsperson's Patent Drawing Review (PTO-948) formation Disclosure Statement(s) (PTO-1449) Paper No | 4) [<br>3) 5) [<br>b(s) 6) [  | Notice of Infor   | imary (PTO-413) Paper<br>mal Patent Application                                | (PTO-152)          |
| 1   | nd Tradomark Office   | A-tion Summant  |   | P  | art of Paper No. 6 |

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## DETAILED ACTION

### Election/Restriction

Application's election without traverse of Group I (Claims 1-5) in Paper No.5 is 1. acknowledge.

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 1 and 3-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Koga (US 2. 5,936,265).

Koga, in related text (Col. 17, Line 57-Col. 18, Line 22 and Col. 24, Lines 16-23) and figures (Figs. 23a-B) disclose a semiconductor device comprising: a resistance layer706 formed on a semiconductor substrate of a first conductivity type and of a second conductivity type, one end of said resistance layer 706 being adapted to have a first voltage (Vss) applied thereto, another end of said resistance layer 706 being adapted to have a second voltage (Vdd) applied thereto; an oxide film 704 formed on the resistance layer706; and a resistance bias electrode layer comprising a silicon layer 705 formed on the oxide film 704; wherein the device is configured so that voltage dependence of a resistance of the resistance layer is reduced by adjusting the voltage applied to the resistance bias electrode layer.

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3. Claims 1-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Choi et al. (US 5,686,754).

Choi et al., in related text (Col. 2, Line 53-Col. 3, Line 51 and Col. 4, Lines 8-55) and figures (Figs. 1-3) disclose a semiconductor device comprising: a resistance layer formed on a semiconductor substrate 20 of a first conductivity type and of a second conductivity type, one end of said resistance layer being adapted to have a first voltage (600V) applied thereto, another end of said resistance layer being adapted to have a second voltage (600V) applied thereto; an oxide film 80 formed on the resistance layer; and a resistance bias electrode layer comprising a silicon layer 7/7a formed on the oxide film 80; wherein the device is configured so that voltage dependence of a resistance of the resistance layer is reduced by adjusting the voltage applied to the resistance bias electrode layer.

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Choi et al.,(US 5,686,754).

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Choi et al., disclose all claimed subject matter, but fails to expressly disclose the ratio of the voltage applied to the pair of the electrode pad layers to the voltage applied to the resistance bias layer is 0.5-0.6.

Choi, in related text, (Col. 2, Lines. 53-65) disclose the ratio of the voltage applied to the pair of the electrode pad layers to the voltage applied to a resistance bias electrode layer is 0.98 (600V/615V). It would have been obvious to one with ordinary skill in the art at the time of the invention to judiciously adjust and control the ratio of the voltage applied to the pair of the electrode pad layers to the voltage applied to the resistance bias layer through routine experimentation and optimization to achieve optimum benefits (see MPEP 2144.05) and it would not yield any unexpected results.

#### Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Vu whose telephone number is (703) 305-0391. The examiner can normally be reached on Monday-Friday from 8:00am to 5:00pm.

If attempt to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms., can be reached on (703) 308-4910.

DV

David Vu

HOAIHO
PRIMARY EXAMINER